



IFW AFASB
Patent
CIT.PAU.01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:
Scherer et.al.

Examiner: R.McDonald
Group Art Unit: 1753

Serial No.: 10/068,283

Filed: Feb. 5, 2002

For: Dry Etching and Mirror
Deposition Processes for Silicone
Elastomer

AMENDMENT AFTER FINAL

Hon. Commissioner of Patents and Trademarks
Washington DC 20231

Sir:

In reply to the Office Sept. 10, 2004, please consider the following
remarks and enter the following amendments. Enclosed is a check for
additional claims added by this amendment.

Amendments to the Claims are reflected in the listing of claims which
begins on page 2 this paper.

Remarks begin on page 8 of this paper.

09/28/2004 FHETEKI1 00000013 10068283

01 FC:2201
02 FC:2202

43.00 OP
27.00 OP

DO NOT
ENTER 10/16/04